BASIC ELECTRONICS MID TERM QUESTION 2021 (ODD SEMESTER)

Q1. In aPN junction diode, the current in reverse bias may be
Options are:
Options are.
The junction current is due to minority carriers only
The junction current at equilibrium is zero as equal but opposite carriers are crossing the junction
The junction current reduces with rise in temperature
The junction current at equilibrium is zero as charges do not cross the junction
Q2. In a PN junction when the applied voltage overcomes the potential, the diode current is large, which is known as
Options are:
Depletion, negative bias
Reverse, reverse bias
Resistance, reverse bias
Barrier, forward bias
Q3. Mobile electrons of P-side of the PN junction diode constitute
Options are:
Minority current carriers
Majority current carriers
Depending upon voltage they may be either majority or minority current carriers
None of the above

Q4. Barrier potential in a PN junction is caused by

Options are:

Flow of drift current

Diffusion of majority carriers across the junction

Migration of minority carriers across the junction

Thermally-generated electrons and holes

Q5. Which of the following expression represent the correct formulae for calculating the exact position of the Fermi level for p-type material?

Options are:

$$E_F = E_V + kTln(N_D / N_A)$$

$$E_F = -E_V + kTln(N_D / N_A)$$

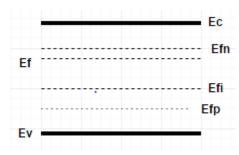
$$E_F = E_V - kT ln(N_D / N_A)$$

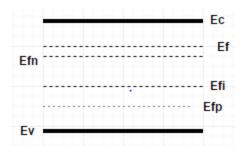
$$E_F = -E_V - kT ln(N_D / N_A)$$

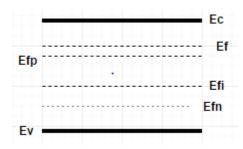
Q6. If the excess carriers are created in the semiconductor, then identify the correct energy level diagram.

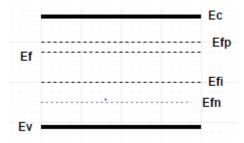
Options are:

(correct answer is 1st one)









Q7. The thermal equilibrium concentration of the electrons in the conduction band and the holes in the valence band depends upon?

Options are:

Effective density of states

Fermi energy level

Both A and B

Neither A nor B

Q11. If Ef>Efi, then what is the type of the semiconductor?
Options are:
n-type
p-type
elemental
compound
Q12. Formation of a junction between a sample of P-type and N-type material causesaction
Options are:
Rectifying
Conducting
Insulating
None of the above
Q13. The reverse saturation current in a Silicon Diode is than that of Germanium Diode
Options are:
Equal
Higher
Lower
Depends on temperature

Q14. A semiconductor has temperature coefficient of resistance.
Options are:
Positive
Zero
Negative
None of the above
Q15. The random motion of holes and free electrons due to thermal agitation is called
Options are:
Diffusion
Pressure
Ionisation
None of the above
Q16. When the temperature of an extrinsic semiconductor is increased, the pronounced effect is on
Options are:
Junction capacitance
Minority carriers
Majority carriers
None of the above

Q17. If the temperature of a crystal diode increases, then leakage current
Options are:
remains the same
decreases
increases
becomes zero
Q18. If the doping level of a crystal diode is increased, the breakdown voltage
Options are:
remains the same
is increased
is decreased
none of the above
Q19. The knee voltage of a crystal diode is approximately equal to
Options are:
applied voltage
breakdown voltage
forward voltage
barrier potential

Q20. If the doping level in a crystal diode is increased, the width of depletion layer...........

Options are:

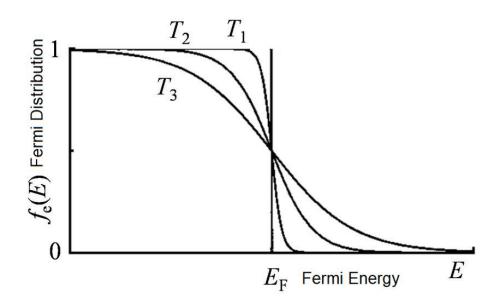
remains the same

is decreased

in increased

none of the above

Q21. What is the relationship between T1, T2 and T3?



Options are:

T1 > T2 > T3

T1 < T2 < T3

T1 = T2 = T3

Insufficient Information

Q22. When a little amount of Arsenic is doped with pure Silicon metal, what does one get?
Options are:
Intrinsic semiconductor
Insulator
N-type semiconductor
P-type semiconductor
Q23. In a PN junction the potential barrier is due to the charges on either side of the junction, these charges are
Options are:
Majority carriers
Minority carriers
Both (a) and (b)
Fixed donor and acceptor ions
Q24. A PN junction
Options are:
Has low resistance in forward as well as reverse directions
Has high resistance in forward as well as reverse directions
Conducts in forward direction only
Conducts in reverse direction only

Q25. In a p-type semiconductor, germanium is doped with which of the following?
Options are:
Gallium
Copper
Phosphorous
Nitrogen
Q26. Determine the probability that an energy level is filled of an electron if the state is above the Fermi level by 2kT?
Options are:
11 x 10 ^-2
55 x 10 ^ -5
22 x 10 ^ -6
33 x 10 ^-4
Q27. Assume an ideal PN junction with the doping density in P-side is higher compared to that in n-side. Which of the following comments is correct regarding the spread of the depletion region in n and p sides?
Options are:

Depletion region is extended more inside p-doped region compared to n-doped region.

Depletion region is extended more inside n-doped region compared to p-doped region.

Depletion region is extended equally inside n and p doped regions.

Depletion widths inside both n and p doped regions become zero at thermal equilibrium.

Q28. The magnitude of the current through a practical PN junction diode, which is subjected to a low reverse bias, is observed to increase slowly with the increase in applied voltage in the reverse direction. Which one of the following is the most possible reason for this non-ideal behavior?

Options are:

Recombination of electron-hole pairs in the depletion region.

Impact of series resistance.

High level injection of minority carriers that surpass the background doping concentration.

Generation of electron-hole pairs in the depletion region.

Q29. According to Fermi-Dirac statistics, at temperatures more than 0 K, the probability of occupation at Fermi energy (E_F) is:

Options are:

0.5

0

0.75

1

Q30. Calculate the forward bias current of a Si diode at 300 K when forward bias voltage of 0.4V is applied, the reverse saturation current is 1.17×10 -9A and η (ideality factor) =1.

Options are:

6.969 mA

8.23 mA

1.256 mA

5.689 mA